3D Imaging of Nanostructures Using Electron Tomography, and the Impact of Aberration Correctors



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## **Tomographic Reconstruction**

**<u>Goal</u>**: 3D information from thick, crystalline, high atomic number materials

- Measure structure thicknesses, x-sections, CDs Challenges:

 Image intensities for electron tomography must be monotonic with thickness

Not Conventional TEM

- Contrast reversal in HAADF Scanning TEM (Z-contrast)
  High mass-thickness materials appear dark at high tilts
- Samples must be tilted to ±70° to recover 3D information

Tilting causes translations and rotations between images that must be corrected (post-processing) Impact of aberration correctors:

- Lateral and depth resolution significantly improved
  - Depth resolution < sample thickness</p>



# **Tomography Experiment**



### Acquisition

#### For the best results:

- Acquire many images over as large a tilt range as possible
  - $\rightarrow$  One every 1-2° from ±70°





### Reconstruction

#### Requires:

- Accurate spatial alignment
- Determination of tilt axis
- Accurately spaced angular increments

# V2 Via Liner Layer by HAADF STEM

#### Etch Roughness





## **Contrast Reversal in HAADF STEM**





## **Contrast Reversal with Thickness**



- HAADF STEM
- 0° tilt



- HAADF STEM
- 70° tilt

## Why the Contrast Reversal in HAADF?



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## Maximum Material Thickness: HAADF vs IBF

Apparent thickness is increased ~threefold by tilting





# IBF vs. HAADF for Cu: SNR



Question: when does IBF become advantageous over HAADF?

– Compare for  $\Delta t$ =5nm at relevant thicknesses

• IBF is better even before contrast reversal thicknesses are reached

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# **Stress Void Reconstructions**

### <u>HAADF</u>









## Stress Void and Via Reconstruction





# **Copper Line Resistivity**



- TEM data from L. Gignac



- By preparing one sample for tomography we can gain information about ~2nm slices of each line.
- Getting the same information by CTEM requires preparation and measurement of many samples.



# **Electron Lens Aberrations**



• Use circular aperture to cutoff electrons with a large phase shift  $\Delta s$  across the lens





- The image of a point transferred through a lens with a circular aperture of semiangle  $\alpha_0$  is an Airy disk of diameter:  $d_0 \propto 1/\alpha_0$
- Balance spherical aberration against the aperture's diffraction limit
  - Less diffraction with a larger aperture
- Design correctors to eliminate phase shift across the lens
  - Lens aberrations are a non-convergent power series
    - Correct  $C_3 \rightarrow C_5$ ; Correct  $C_5 \rightarrow C_7$ ; ETC...

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# **Prospects for Depth Sectioning**

Current STEM correctors:  $\Delta z \sim 3-8 \text{ nm}$  Super STEM:  $\Delta z \sim 1 \text{ nm}$ ?



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# **Tomography or Depth Sectioning**



Focal Series: Change defocus to sample at different depths Tilt Series: Tilt sample to fill Fourier-Space with projections



# Information Limit for Depth Sectioning





Half-angle:  $2\alpha_{max}$ 

k<sub>r</sub> cutoff:

 $\frac{2\alpha_{\max}}{\lambda}$ 

 $C_3$  limited: 9.6mrad = .55° covers:1.1°

 $C_5$  limited: 29mrad = 1.66° covers : 3.32°



## Fourier Reconstruction with Depth Sectioning at Different Tilts



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# **Fourier Reconstruction Methods**

#### **Tilt Series**

#### **Focal & Tilt Series**





# Convolution Simulation: PSF



200keV, C<sub>3</sub>=-0.0842mm, C<sub>5</sub>=100mm, f<sub>0</sub>=-132,  $\alpha$ =29.1mRad ±70° @ 7° increments



# Spread of PSF Intensity



• Intensity is decentralized for both methods



# **Convolution Simulation: CTF**





# **Depth Resolution**



- Depth information from focal series does not add to depth resolution
- Tomography resolution: experiment is 1-2nm (Why!?)
  - Tomography yields 10x worse resolution in practice Alignment, stage movement (low mag)

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# **Conclusions: Tomography & Correctors**



### Electron Tomography

- Quantitative measurements of 3D objects
- Incoherent Bright Field (IBF) STEM
  - high  $\rho^* Z$  and t
- Impact of Correctors
  - Improved lateral and depth resolution
  - Focal and Tilt series
    - necessary for corrected instruments
    - 3x fewer tilts needed  $\rightarrow$  Faster!
  - Resolution limits
    - No considerable increase in resolution predicted
    - Tilt stage quality, alignment, blurring





## **Contrast Reversal with Thickness**



- HAADF STEM
- 0° tilt



- HAADF STEM
- 70° tilt

# Cu lines: Planview





## Increasing the Collector Angle ( $\theta_c$ )





# Fourier Reconstruction

"A 2D projection of a object is equivalent to a 2D slice through the Fourier transform of that object at the angle of projection."



**Weighted backprojection:** Backprojection can be made more accurate by restoring the correct distribution of the spatial frequencies using a weighting filter.



# **Tomographic Reconstruction**



### **Under sampling**

Yields a blurred reconstruction



### **Missing wedge**

Features perpendicular with the tilt axis are distorted



# Z-contrast Simulation Method



3D incoherent Z-contrast STEM imaging simulation



# Fourier Slice Theory



# **Aberration Correctors**

Lens aberrations create phase shifts for e-'s incident at different angles

$$\chi(\alpha) = \frac{2\pi}{\lambda} \left( -\frac{1}{2} \Delta f \alpha^2 + \frac{1}{4} C_3 \alpha^4 + \frac{1}{6} C_5 \alpha^6 + \frac{1}{8} C_7 \alpha^8 + \cdots \right)$$
$$\chi_{\text{max}} = \pi/2$$

- For given C-values...maximize  $\boldsymbol{\alpha}$  to maximize resolution
  - Including depth resolution  $\Delta z$

$$\Delta z \propto \frac{1.22\lambda}{\alpha^2}$$



# Balance Spherical Aberration Against Diffraction

• Balance sperical aberration against the aperture's diffraction limit

- Less diffraction with a large aperture must be balanced against C3
- For a rough estimate of the optimum aperture size, convolve blurring terms
  - Add in quadrature:  $d_{tot}^2 \approx d_0^2 + d_s^2$



# **Electron Lens Aberration Correctors**

Design corrector to give no phase shift across the lens There are other higher order aberrations that limit resolution Lens aberrations are a power series that does not converge You can correct C3 but C5 limits you, correct C5 but C7 limits you, etc...

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